

## IN THE UNITED STATEMENT AND TRADEMARK OFFICE

In re Application of

Customer Number: 20277

Douglas J. BONSER, et al.

Confirmation Number: 5274

Application No.: 10/791,759

Group Art Unit: 2818 Allowed: April 06, 2006

Filed: March 04, 2004

Examiner: Tran, Long K.

For: METHOD OF REDUCING STI DIVOT FORMATION DURING

SEMICONDUCTOR DEVICE FABRICATION

## **LETTER SUBMITTING FORMAL DRAWINGS**

Mail Stop Issue Fee Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In response to the Notice of Allowability dated April 06, 2006, submitted herewith are eleven (11) sheets of Formal Drawings in connection with the above referenced application.

Respectfully submitted,

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Please recognize our Customer No. 20277 as our correspondence address.